High Breakdown Voltage, Fully Depleted Series

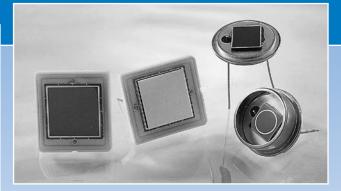
Large Active Area Photodiodes

The Large Active Area High Speed Detectors can be fully depleted to achieve the lowest possible junction capacitance for fast response times. They may be operated at a higher reverse voltage, up to the maximum allowable value, for achieving even faster response times in nano seconds. The high reverse bias at this point, increases the effective electric field across the junction, hence increasing the charge collection time in the depleted region. Note that this is achieved without the sacrifice for the high responsivity as well as active area.

The Large Active Area Radiation Detectors can also be fully depleted for applications measuring high energy X-rays, γ-rays as well as high energy particles such as electrons, alpha rays and heavy ions. These types of radiation can be measured with two different methods. Indirect and direct.

Indirect High Energy Radiation Measurement:

In this method, the detectors are coupled to a scintillator crystal for converting high energy radiation into a detectable visible wavelength. The devices are mounted on a ceramic and covered with a clear layer of an epoxy resin for an excellent optical coupling to the scintillator. This method is widely used in detection of high energy gamma rays and electrons. This is where the X-UV devices fail to measure energies higher than 17.6 keV. The type and size of the scintillator can be selected based on radiation type and magnitude.



APPLICATIONS

Large Active Area

High Speed Detectors Laser Guided Missiles

- Laser Warning
- Laser Range Finder
- Laser Alignment
- Control Systems

Large Active Area Radiation Detectors

- Electron Detection
- Medical Instrumentation
- High Energy Spectroscopy
- Charged Particle Detection
- High Energy Physics
- Nuclear Physics

FEATURES

- Large Active Area
- High Speed Detectors
- Large Active Area
- Fully Depleteable
- Fast Response
- Ultra Low Dark Current
- Low Capacitance

Large Active Area

- Radiation Detectors
- Large Active Area
- Scintillator Mountable • Fully Depleteable
- Ultra Low Dark Current
- Low Capacitance
- High Breakdown Voltage

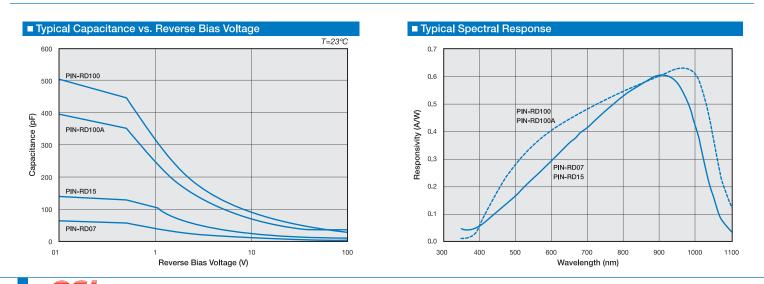
Direct High Energy Radiation Measurement:

Both PIN-RD100 and PIN-RD100A, can also be used without any epoxy resin or glass window for direct measurement of high energy radiation such as alpha rays and heavy ions. The radiation exhibits loss of energy along a linear line deep into the silicon after incident on the active area.

The amount of loss and the penetration depth is determined by the type and magnitude of the radiation. In order to measure completely the amount of radiation, the depletion layer should be deep enough to cover the whole track from the incident point to the stop point. This requires a high bias application to fully deplete the detector. In spite of the large active area as well as high bias voltage applications, the devices exhibit super low dark currents, low capacitances and low series resistances.

In addition to their use in high energy particle detection, the PIN-RD100 and PIN-RD100A are also excellent choices for detection in the range between 350 to 1100 nm in applications where a large active area and high speed is desired.

These detectors can be coupled to a charge sensitive preamplifier or lownoise op-amp as shown in the opposite page. The configuration for indirect measurement is also shown with a scintillator crystal.



Fully Depleted Photodiodes

Typical Electro-Optical Specifications at T_A=23°C

mber	Active Area		onsivity ngth)	Responsivity (A/W)	Depletion Voltage	Dark Current (nA)		Capacitance (pF)				Reverse Voltage (V)	Tem Rar (°	ige	
Model Nu	Area (mm²) Dimensions (mm)		ak Responsiv Wavelength (nm)	900 nm	v	-100 V		-100 V		900 nm -100 V 50Ω	900nm -100V	10 µA	ating	rage	Package Style ¶
		Pe	typ.	typ.	typ.	max.	typ.	max.	typ.	typ.	max.	Oper	Sto		
Large Active Area, High Speed															
PIN-RD07	7.1	3.00 ¢	900	0.55	48	0.2	5.0	8.0	9.0	1.5	1.2 e-14	135	o, 00	55 , ,25	26 / TO-8

PIN-RD07	7.1	3.00 φ	900	0.55	48	0.2	5.0	8.0	9.0	1.5	1.2 e-14	135	0,00	5 25 25	26 / TO-8
PIN-RD15	14.9	4.35 φ		0.58	55	1.0	30	14	16	3.0	2.5 e-14	140] ⁺ , ⁺	+ ۲	20710-8
PIN-RD100	100	10 Sq	950	0.60	75	2 †	10 †	50 †	60 †		3.2 e-14	120	0,000	20 80	25 / Ceramic
PIN-RD100A	100	10 Sq		950	950 0.60	35	2	10	40	45		3.4 e-14	70		Ϋ́ΥΨ

mber	Active Area		onsivity ngth)	Responsivity 900 nm	Capacitance (pF)	Shunt Resistance (GΩ)		NEP (W/√Hz)	Rise Time (ns)	Tem Rar (°	ige	Package Style ¶
Model Nu	(mm²)	Dimensions (mm)	Peak Responsivity Wavelength (nm)	A/W 0 V		-10 V		900 nm	0 V 632nm 50Ω	ating	rage	
2	Area Dime		Pe	typ.	typ. min. typ.		typ.	typ.	Oper	Stol		
OSD35-LR Series												
OSD35-LR-A	34.2	5.8 x 5.9	830	0.54	1300	2	3	5.6 e-15		+75	+100	25.4.0
OSD35-LR-D	34.2	5.8 x 5.9	830	0.54	1300	0.1	0.3	1.8 3-14		-25 ~	-45 ~	25 / Ceramic

OSD-35-LR's ceramic packages come without window, instead the optically clear epoxy is used.

† Measured at Vbias = -50V

¶ For mechanical drawings please refer to pages 58 thru 69.

* Non-Condensing temperature and Storage Range, Non-Condensing Environment.

DIRECT DETECTION

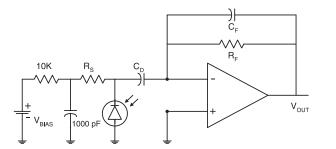
For direct detection of high-energy particles, the pre-amplifier is a FET input op-amp, followed by one or more amplification stages, if necessary, or a commercial charge sensitive preamplifier. The counting efficiency is directly proportional to the incident radiation power. The reverse bias voltage must be selected as such to achieve the best signal-to-noise ratio. For low noise applications, all components should be enclosed in a metal box. Also, the bias supply should be either simple batteries or a very low ripple DC supply. The detector should also be operated in the photovoltaic mode.

Amplifier: OPA-637, OPA-27 or similar

- R_{F} : 10 M Ω to 10 G Ω
- R_s : 1 M Ω ; Smaller for High Counting Rates
- C_F: 1pF C_D: 1pF to 10 μF

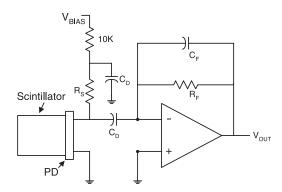
OUTPUT $V_{OUT} = Q / C_F$

Where Q is the Charge Created By One Photon or One Particle



INDIRECT DETECTION (WITH SCINTILLATOR CRYSTAL)

The circuit is very similar to the direct detection circuit except that the photodiode is coupled to a scintillator. The scintillator converts the high-energy X-rays and/or X-rays into visible light. Suitable scintillators include CsI(TL), CdWO4, BGO and NaI(TL). The amplifier should be a FET input opamp, followed by one or more amplification stages, or a commercial charge sensitive preamplifier. The output voltage depends primarily on the scintillator efficiency and should be calibrated by using radioactive sources.



1. Parameter Definitions:

- A = Distance from top of chip to top of glass.
- a = Photodiode Anode.
- B = Distance from top of glass to bottom of case.
- c = Photodiode Cathode
 - (Note: cathode is common to case in metal package products unless otherwise noted).
- W = Window Diameter.
- F.O.V. = Filed of View (see definition below).

2. Dimensions are in inches (1 inch = 25.4 mm).

3. Pin diameters are 0.018 ± 0.002" unless otherwise specified.

4. Tolerances (unless otherwise noted) General: 0.XX ±0.01" 0.XXX ±0.005" Chip Centering: ±0.010"

Dimension 'A': ± 0.015 "

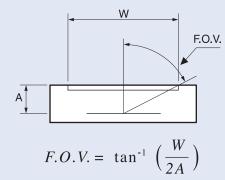
5. Windows

All '**UV**' Enhanced products are provided with QUARTZ glass windows, 0.027 \pm 0.002" thick.

All 'XUV' products are provided with removable windows.

All '**DLS**' PSD products are provided with A/R coated glass windows.

All 'FIL' photoconductive and photovoltaic products are epoxy filled instead of glass windows.





Mechanical Specifications and Die Topography

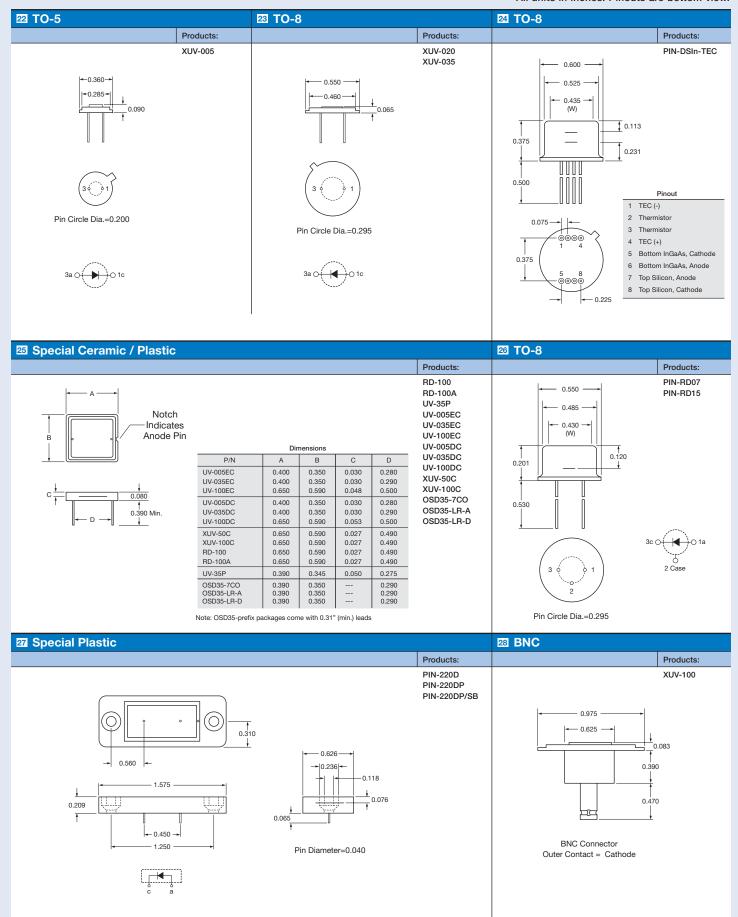
For Further Assistance Please Call One of Our Experienced Sales and Applications Engineers

310-978-0516

- Or -On the Internet at WWW.OSioptoelectronics.com

Mechanical Specifications

All units in inches. Pinouts are bottom view.



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